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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Weis, *et al.* Docket No.: 02P15178US/INTECH 3.0-079  
Serial No.: 10/774,827 Art Unit: 2822  
Filed: February 9, 2004 Examiner: Trinh, Michael Manh  
For: Line Mask Defined Active Areas for 8F2 DRAM Cells with Folded Bit Lines and Deep Trench Patterns

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

AMENDMENT ACCOMPANYING RCE

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's Office Action mailed June 14, 2006. Please amend the above-referenced application as follows.

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